

# Inkjet printing of tungsten sol-gel ink

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**Abstract:** Tungsten (VI) oxide –  $WO_3$  is one of the widely studied inorganic semiconductors with outstanding chromogenic properties. Its unique optical and electrical properties enable application in energy efficient systems (e.g. smart windows), sensors, displays, storage units, electric and photo catalysts and solar cells. The  $WO_3$  layers are mostly made by expensive vacuum sputtering (PVD), chemical vapour deposition (CVD) and electro-deposition, but it is also possible to deposit layers from sol-gel solutions using dip-coating or spin-coating. On the other hand printing of the  $WO_3$  layers is unexplored area, although enabling flexibility of the substrates, patterning, multi-layer deposition and R2R mass production favouring low cost of the final devices. According to our knowledge this is the first report showing the feasibility of inkjet printing of tungsten sols.

**Keywords:** inkjet printing, peroxopolytungstic sol,  $WO_3$ , chromism

## 1 Introduction

Tungsten (VI) oxide –  $WO_3$  is identified as one of the most efficient inorganic electrochromic material. It has excellent electrochromic properties in the visible and infrared part of the spectrum and enables high optical modulation at relatively low price. It can be used as a buffer layer or p-/n-type semiconductor, therefore applicable in a range of different applications like sensors, displays, storage units, electric and photo catalysts and solar cells etc [1]–[5].

$WO_3$  layers are mostly made by RF vacuum sputtering, chemical vapor deposition (CVD), electrodeposition or coating of suspensions or solutions made by sol-gel processing (e. g. dip-coating and spin-coating) [1]. Coating techniques are limited in control of deposition, multi-layered structures and patterning. Today electronic systems production dictates cheaper and adoptable mass production. Due to increasing market demands of consumer electronics at low cost conventional and digital printing techniques are gaining importance. Nowadays inkjet printing is one of the most promising technique as it enables precise and contact-less transfer, the use of many materials, sampling and selective multi-layer construction [6]. Nevertheless the inkjet printing requires precise development of the solutions/inks for the particular substrate as well as precise adaptation of printing settings to avoid defects in printouts such as inhomogeneous film formation, formation of cracks, irregular deformed lines and other defects (e.g. coffee ring, fishbone effect etc.) [7]–[8]. Regarding the solution/ink properties the viscosity, surface tension, and evaporation rate of the ink should be carefully adjusted taking into account also printing settings such as voltage of pulse, substrate and ink temperature, size and speed of ink drops, etc. [9]. The viscosity, surface tension and evaporation rate of the ink can be controlled by combining solvents, as recently reported by Chouiki and Schoeftner [10]. Optimal ink for Drop on Demand – DOD inkjet system should have the viscosity around 0.01 Pas (0.002–0.03 Pas) and the surface tension around 30 mN/m [11]. Furthermore, the viscosity needs to be high enough to allow the smooth delivery of the ink between the printer head and the cartridge, while the surface tension of the ink plays an important role on the interaction between the printer nozzle and ink, as well as on the spreading of drops over the substrate surface. Ideally, the surface tension must

be high enough to be held in the nozzle without dripping and low enough to allow the droplet spreading over the substrate surface to form a continuous film [12]. It is important to mention that homogeneity of printouts depends also on drop formation mechanism which is influenced by fluid and surface properties.

Drop dynamics and the interaction between droplet and substrate surface are of great importance when deposition techniques such as spraying or inkjet printing are used. Various dynamic phenomena are observed during drop formation such as splashing, spreading, receding, bouncing and crown formation [13]. Printability of the inks, drop dynamics and film formation can be predicted with various computational simulations using different theoretical models [14]–[17]. The printability of the ink could be assessed with the Z number ( $Z = \sqrt{d} \cdot \sigma \cdot \delta / \eta$ ), where  $d$  is the diameter of nozzle,  $\sigma$  is the surface tension,  $\delta$  is the density and  $\eta$  is the viscosity of printable liquid. Some theories predict a stable drop formation when  $Z > 2$  [18] while others determined that a printable fluid should have a Z value between 1 and 10 [19]. The lower limit is governed by the viscosity of fluid and its printing ability, while upper limit is determined by the point at which multiple drops are formed instead of single droplet [17].

Printing of functional sol-gel materials is a new and underexplored area of research. Inkjet printing of sol-gel functional materials is very complex and in addition to fine tuning of rheological properties of the solutions, there is a necessity to control the gelation of sols and interactions between different materials. There are some reports describing inkjet printing of inorganic layers (e.g. SiO<sub>2</sub>, ZnO, TiO<sub>2</sub>, V<sub>2</sub>O<sub>5</sub> etc.) which were used as transparent electrically conductive and dielectric substrates, components for photoactive layers, layers for chromogenic systems and sensors [6], [10][12][18]. According to our knowledge the only relevant publication [20] referring printing of WO<sub>3</sub> material describes inkjet printing of suspensions based on TiO<sub>2</sub> and WO<sub>3</sub> nanopowders with different solvents and additives.

In this contribution we focus on inkjet printing of sol-gel derived tungsten solution on glass substrate. Our major challenge in applying inkjet printing technique for the deposition of functional tungsten material was the formulation of ink with suitable viscosity and surface tension. The peroxo sol-gel synthesis [21] was used to prepare the peroxo polytungstic acidic sols which were then further modified with different solvents in order to obtain suitable jetting solution. Furthermore, we characterize the rheological and physicochemical properties of WO<sub>3</sub> sols and the morphology and the quality of the transparent WO<sub>3</sub> printouts.

## 2 Experimental

### 2.1 Preparation of WO<sub>3</sub> sol

Firstly, we synthesized peroxo-tungsten acid (PTA) by reacting 5 g of tungsten monocrystalline powder (99.9 %, Aldrich) and 20 ml of hydrogen peroxide (30 %, Belinka). The sol was prepared by heating the PTA solution to 120 °C and during stirring a solvent was added. We prepared two WO<sub>3</sub> sols based on two different solvents, namely isopropanol (puriss, Sigma-Aldrich) and mixture of isopropanol and 2-propoxy ethanol (puriss, Sigma-Aldrich). Sols are named as WO<sub>3</sub>-1 for WO<sub>3</sub> sol based on isopropanol and as WO<sub>3</sub>-2 for WO<sub>3</sub> sol based on a mixture of isopropanol and 2-propoxy ethanol. Prepared sols were orange and contained 5 g of tungsten powder in 30 ml of WO<sub>3</sub> sol.

### 2.2 Inkjet printing of WO<sub>3</sub> layers

Glass substrates were cleaned with 2 vol. % Mucosol (Sigma Aldrich) aqueous solution, distilled water and isopropanol or with a mixture of isopropanol and 2-propoxy ethanol. Inkjet printing was performed using a piezoelectric Dimatix Materials Printer Series 2800 (Fujifilm Dimatix Inc.) equipped with silicon print head cartridges having 16 nozzles, each with a nominal

drop volume of 10 pL. We varied different printing settings, such as substrate and solution temperature, jetting voltage, printing frequency, drop spacing and cartridge angle.

### 2.3 Characterization

The viscosity of the WO<sub>3</sub> sols was measured at 20 °C using Vibro Viscosimeter model SV-1A. Contact angles, surface tension and surface energy measurements of substrates were carried out using a Krüss DSA 100 goniometer measured by static sessile drop method. The surface free energy was calculated from the measured contact angles of distilled water, diiodomethane and formamide using the Owens-Wendt model. Surface tension of the WO<sub>3</sub> sols was determined with stalagmometric method. Quality and morphology of WO<sub>3</sub> layers was monitored with digital optical camera (Digi 2.0 Micro Scale) and scanning electron microscope (JSM 6060-LV, JEOL). Moreover, image analysis (ImageJ tools) was applied to follow the shape and size of droplets printed at voltages from 10–40 V using different formulations of WO<sub>3</sub> sols on glass substrate.

## 3 Results and discussion

Standard WO<sub>3</sub> sols prepared via peroxy route are based on highly volatile ethanol [21] which has the viscosity of 6.1 mPas and surface tension of 27.2 mN/m at 20 °C. A high evaporation rate of ethanol results in clogged nozzles causing defects on layers like inhomogeneity, coffee ring, fishbone effect etc [7]. Therefore we modified the synthesis of the WO<sub>3</sub> sol by replacing ethanol with isopropanol (sol WO<sub>3</sub>-1) and mixture of isopropanol and 2-propoxy ethanol (sol WO<sub>3</sub>-2). The result was higher viscosity of the sols and more suitable surface tension, while the addition of 2-propoxy ethanol, as a solvent with higher boiling point (b. p. 150–150 °C; [23]) slows down the evaporation, for details see Table 1.

Table 1: Density, viscosity, surface tension and Z number of WO<sub>3</sub> sols at 20 °C

WO <sub>3</sub> sols	Density (g/cm <sup>3</sup> )	Viscosity (mPas)	Surface tension (mN/m)	Z number (l)
WO <sub>3</sub> -1	1.054	8.41	22.1	2.566
WO <sub>3</sub> -2	1.124	11.1	25.5	2.157

The surface tension of the substrate has to be 10 mN/m higher than the surface tension of the printable liquid to achieve good wetting. Diodomethane, distilled water and formamide were used as test liquids to determine the surface tension of glass substrate. The results of surface tension measurement reveal that the surface free energy of glass substrate is 63.1 mN/m, which is still 30 mN/m higher when compared to the surface tension of the sols. Results disclose that the surface tension of substrates and solution are not perfectly matched. Further improvements like surface cleaning and treatment of substrates or modifications of solution are needed to further optimize the printing process.

Dynamics of droplets and formation of printed film can be predicted by theoretical models as described in the introduction part. To determine the printability of WO<sub>3</sub> sols, the calculations of Z number ( $Z = \sqrt{d \cdot \sigma \cdot \delta / \eta}$ ) was made. Firstly, we determined the velocity of sols (v) droplets at different voltages using Dimatix Drop Watcher set-up. The results are shown in Figure 1. As expected, printing velocity increases with increasing the voltage.

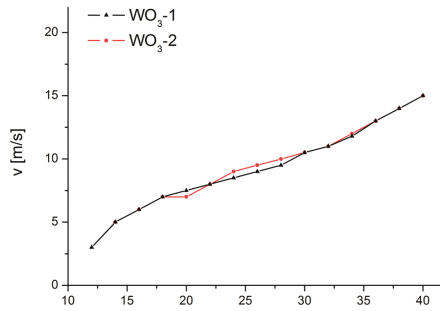


Figure 1: The velocity of WO<sub>3</sub> sols vs. applied voltage

The printability of the ink was assessed with the Z number. In our study the Z values were around 2 for WO<sub>3</sub> sols, respectively (Table 1). Therefore, regardless of the differences in the theories we presume good printability of the WO<sub>3</sub> sols.

We have analysed printed WO<sub>3</sub> droplets deposited on glass substrate at different voltages with digital optical camera, SEM and image analysis. Image analysis of printed WO<sub>3</sub> droplets using two different WO<sub>3</sub> sols on glass substrates while applying different voltage was made. The results are presented in Figure 2 and 3 showing that WO<sub>3</sub>-2 sol illustrates better droplet interaction with glass substrate and minor defects. Results also show the impact of increasing printing voltages to the shape and size of droplets. The droplets area is 0.11 mm<sup>2</sup> and goes up to 0.23 mm<sup>2</sup> applying 19 V and 40 V, respectively.

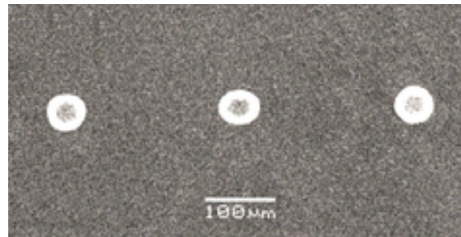


Figure 2: SEM image of WO<sub>3</sub> droplets (sol WO<sub>3</sub>-2) on glass substrate printed at 19 V

Figure 3 shows SEM image of WO<sub>3</sub> droplets using sol WO<sub>3</sub>-2 sol on glass substrate printed at 19 V. The image indicates a minor deformation of droplets in shape and size. The estimated diameters of droplets printed using WO<sub>3</sub>-2 sol are around 0.08 mm.

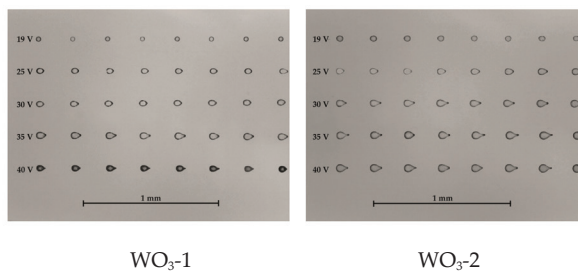


Figure 3: Optical images of dried WO<sub>3</sub> droplets printed on glass at voltages of 19–40 V using WO<sub>3</sub>-1 and WO<sub>3</sub>-2 inks

Nevertheless while printing  $\text{WO}_3$  sols we were faced with various problems (e.g. misdirected nozzles, non-jetting nozzles, non-matched velocities etc), which were related to improper rheological and physicochemical properties of the  $\text{WO}_3$  sols. The improper printing settings (e.g. voltage, frequency, drop spacing and temperature) and inappropriate properties of the  $\text{WO}_3$  sol (e.g. viscosity and surface tension) resulted in different defects of printouts such as fishbone defect and inhomogeneous layer formation (Figure 4). An example of transparent  $\text{WO}_3$  printout that does not show optical defects is shown in Figure 5.

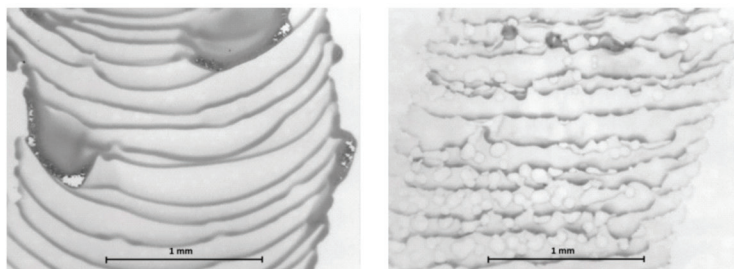


Figure 4: Defects in inkjet printing of  $\text{WO}_3$  sol; fishbone (left) and inhomogenous layer (right)

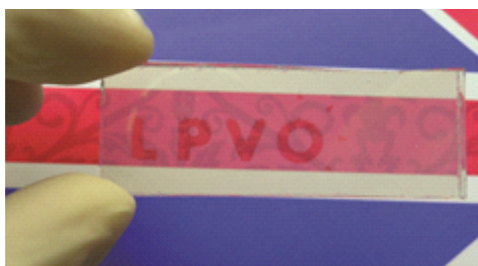


Figure 5: Inkjet transparent  $\text{WO}_3$  printout

#### 4 Conclusions

The results show that it is possible to realize transparent  $\text{WO}_3$  layers free of optical defects with ink-jet printing using sol-gel derived  $\text{WO}_3$  solution. The rheological and physicochemical properties of  $\text{WO}_3$  sols can be adjusted for inkjet printing. In general, the results of this study open a new way for  $\text{WO}_3$  layer manufacturing and could significantly utilize future development of chromogenic as well as other optoelectronic device.

#### Acknowledgments

Slovenian Research Agency is acknowledged for funding the Research Programme P2-0197. Tjaša Vidmar would personally like to acknowledge the Slovenian Research Agency for providing her Ph.D. funding.

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